

Main-scenario:

Describe, by interactive animation, the UTwente fabrication process of the transistor.

cleaning

Process flow Transistor

Sub-scenario:

Describe, by interactive animation, a process step, in detail, used during fabrication process of the transistor.

E-beam 🔶

Process steps: •c

Cleaning
Oxidation
Atomic Layer Deposition
Plasma Etching

Wet Etching
E-beam lithography
Sputtering
Dicing

implantat

ion

UNIVERSITY OF TWENTE.

MESA+ Semiconductor Components Group

ALD

oxidation

6/4/11